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IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF	: DATE ALLOWED: 04/20/09
TADAHIRO OHMI, ET AL.	: EXAMINER: VINH, LAN
SERIAL NO: 10/591,294	:
FILED: AUGUST 31, 2006	: GROUP ART UNIT: 1792
FOR: DISTRIBUTOR AND DISTRIBUTING METHOD, PLASMA PROCESSING SYSTEM AND METHOD, AND PROCESS FOR FABRICATING LCD	:

COMMENTS ON THE STATEMENT OF REASONS FOR ALLOWANCE

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

The Applicants acknowledge with appreciation the indication of allowance for the claimed invention. In response to the Examiner's Statement of Reason for Allowance in the Notice of Allowance of April 20, 2009, the Applicants respectfully submit the following comments.

In the Examiner's Statement of Reasons for Allowance on page 2 of the Notice of Allowance, lines 6-7 and lines 14-15 each state, "a first guide wall which projects from the other a second narrow wall." (emphasis added) The Applicants note that the underlined phrase above is not present in Claims 1, 7, 12, 13, and 14 as previously submitted. Accordingly, the above-identified limitation is not relevant to Claims 1, 7, 12, 13, and 14.

In the Examiner's Statement of Reasons for Allowance on page 2 of the Notice of Allowance, lines 16-17 states "in combination with the rest of the limitations of claims 12, 1,

and 14.” (emphasis added) The Applicants note that Claims 12-14 are independent of Claim 1, and any limitation of Claim 1 is not relevant to Claims 12-14.

Respectfully submitted,

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